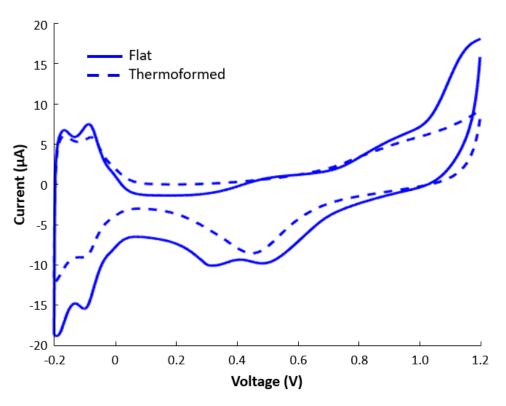


### **Sulfuric Acid, 250 mV/s**

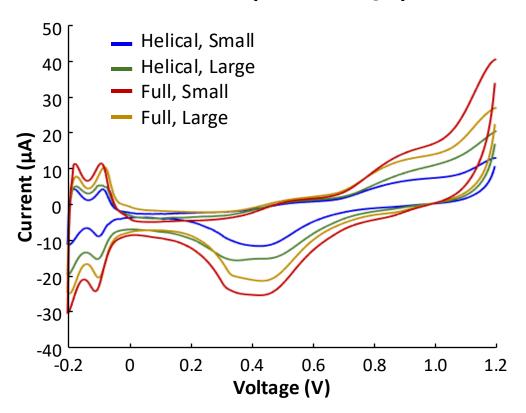


Electrochemical Surface Area = 
$$\frac{H^{+} \text{ Desorption Charge}}{\left(\frac{\text{Charge Density of H}^{+}}{\text{Atoms Adsorped to Pt}}\right)}$$

Charge Storage Capacity = 
$$\frac{\text{Cathodic Charge}}{\text{Geometric Surface Area}}$$



#### Sulfuric Acid, 250 mV/s, Flat

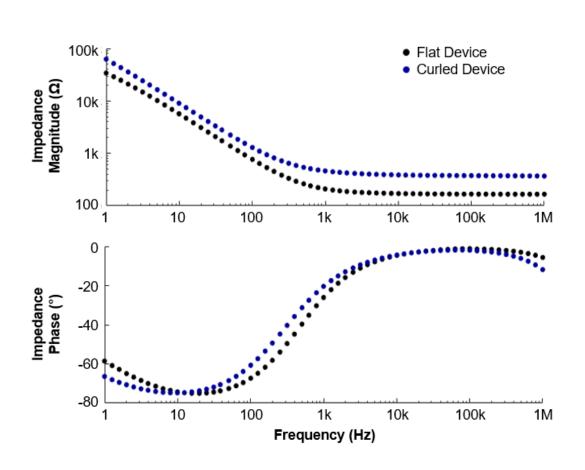


Electrochemical Surface Area = 
$$\frac{H^{+} \text{ Desorption Charge}}{\left(\frac{\text{Charge Density of H}^{+}}{\text{Atoms Adsorped to Pt}}\right)}$$

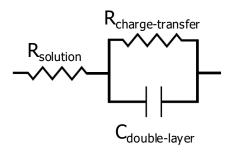
Charge Storage Capacity = 
$$\frac{\text{Cathodic Charge}}{\text{Geometric Surface Area}}$$

Device		GSA	ESA	CSC	
Config	uration	(mm²)	(mm²)	(μC/cm²)	
Helical	Flat	1.7	$1.3 \pm 0.3$	1549 ± 167	
Small	Curled	1.7	Insufficient Data		
Helical Large	Flat	2.8	$2.6 \pm 0.9$	1537 ± 136	
	Curled	2.8	$1.8 \pm 0.6$	1365 ± 208	
Full Flat		4	$3.1 \pm 1.1$	1481 ± 209	
Small	Curled	1.7	$2.3 \pm 0.8$	3107 ± 831	
Full	Flat	3.4	$3.0 \pm 0.7$	1571 ± 176	
Large	Curled	1.6	Insufficient Data		





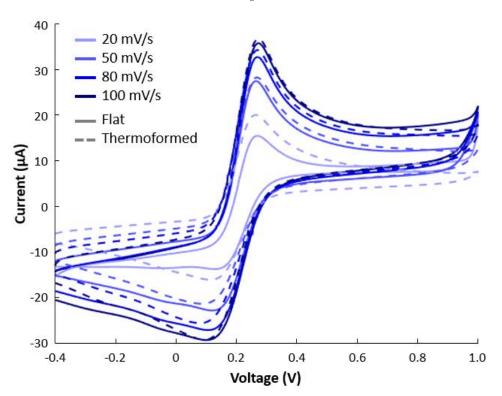
#### **Randles Circuit**



Device Configuration		Z @ 1 kHz (Ω)	
Helical	Flat	No Data	
Small	Curled	$300 \pm 37$	
Helical	Flat	218 ± 15	
Large	Curled	206 ± 14	
Full Small	Flat	No Data	
	Curled	563 ± 178	
Full Large	Flat	184 ± 18	
	Curled	No Data	



#### Ferri/Ferro



Electrochemical Surface Area 
$$\propto \frac{\text{Peak Current}}{\sqrt{\text{Scan Rate}}}$$

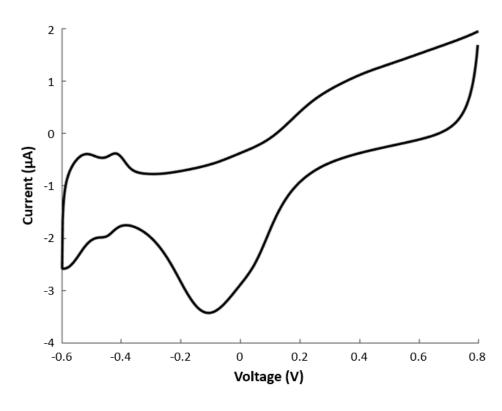
$$i_p = 0.4463nFC\sqrt{\frac{nFvD}{RT}} \times (ESA)$$

Device Configuration		GSA	ESA <sub>FF</sub>	ESA <sub>H2SO4</sub>	ESA <sub>FF</sub> / ESA <sub>H2SO4</sub>
Helical	Flat	1.7	$3.3 \pm 0.2 \text{ mm}^2$	$3.0 \pm 0.3 \text{ mm}^2$	1.1 ± 0.1
<b>Small TF</b> 1.7 2.8 ± 0.3 mm <sup>2</sup>	2.1 ± 0.4 mm <sup>2</sup>	1.4 ± 0.2			
Full Small	Flat	4.0	$7.6 \pm 0.3  \text{mm}^2$	$6.6 \pm 0.5  \text{mm}^2$	1.2 ± 0.1
	TF	1.7	$5.7 \pm 0.5  \text{mm}^2$	$4.3 \pm 0.8 \text{ mm}^2$	1.4 ± 0.3
All Devices	Flat				1.1 ± 0.1
	TF				1.5 ± 0.4

TF = Thermoformed, GSA = Geometric Surface Area, ESA = Electroactive Surface Area, FF = Ferri/Ferrocyanide

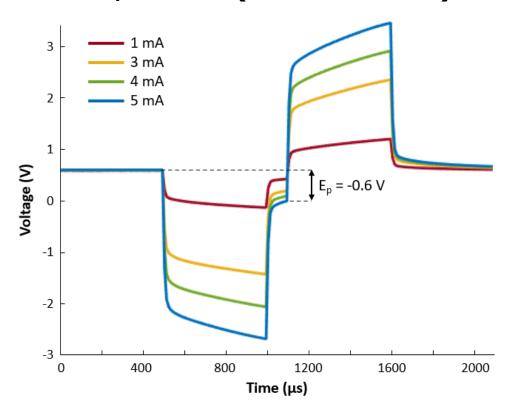


### PBS, 50 mV/s, Curled





#### **VT**, 1x PBS (thermoformed)



$$\frac{\text{Charge Injection}}{\text{Capacity}} = \frac{\binom{\text{Current at}}{\text{E}_{\text{p}} \text{ Limit}} \times (\text{Pulse Width})}{\text{Geometric Surface Area}}$$

Device Configuration		CIC (μC/cm²) @ 200	I <sub>max</sub> (mA) µs	CIC (μC/cm²) @ 500	I <sub>max</sub> (mA) μs
Helical Small	Curled	78 ± 11	6.6	131 ± 43	4.4
Helical Large	Curled	70 ± 3	9.8	93 ± 4	5.2
Full Small	Curled	101 ± 20	8.6	177 ± 48	6.0
Full Large	Curled	Insufficient Data			
Average	Curled	92 ± 21	_	155 ± 52	-

## Electrochemical Testing Summary



Device Co	nfiguration	GSA (mm²)	ESA (mm²)	CSC (µC/cm²)	Z  @ 1 kHz (Ω)	CIC @ 200 μs (μC/cm²)	CIC @ 500 µs (µC/cm²)
Helical, Small	Pre-TF	1.7	$1.3 \pm 0.3$	1549 ± 167	-	-	-
	TF curled	1.7	-	-	$300 \pm 37$	78 ± 11	131 ± 43
Haliaal	Pre-TF	2.8	$2.6 \pm 0.9$	1537 ± 136	$218 \pm 15$	-	-
Helical, Large	TF flat	2.8	$2.4 \pm 0.4$	1469 ± 126	$234 \pm 59$	66 ± 13	91 ± 6
	TF curled	2.8	$1.8 \pm 0.6$	$1365 \pm 208$	$206 \pm 14$	$70 \pm 3$	93 ± 4
Full,	Pre-TF	4	3.1 ± 1.1	1481 ± 209	-	-	-
Small	TF curled	1.7	$2.3 \pm 0.8$	$3107 \pm 831$	563 ± 178	$101 \pm 20$	177 ± 48
Full, Large	Pre-TF	3.4	$3.0 \pm 0.7$	1571 ± 176	184 ± 18	-	-
	TF flat	3.4	-	-	$208 \pm 27$	$130 \pm 16$	178 ± 7
	TF curled	1.6	-	-	-	-	-
Average	Pre-TF	-	-	1526 ± 178	-	-	-
	TF flat	-	-	1469 ± 126	-	107 ± 35	149 ± 43
	TF curled	- -	-	2672 ± 1072	_	92 ± 21	155 ± 52